

**PATENT NUMBER and  
ISSUE DATE**

**U.S. UTILITY Patent Application**

APPL. NUM.	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10010850	12/05/2001	216	434	109	1765 ATWELL, B

APPLICANTS: Clews, Peggy; Mori, Seethambal; 1765

CONTINUING DATA VERIFIED:

None BT

**BEST AVAIL AV**

CONTINUING APPLICATIONS VERIFIED:

None BT

DO NOT PUBLISH <input checked="" type="checkbox"/>	RESCIND <input type="checkbox"/>	ATTORNEY DOCKET NO.
Priority, if any claimed PCT/US01/09,000,000 filed	<input type="checkbox"/> Yes <input checked="" type="checkbox"/> No	SD6957897604
Priority and Acknowledged Examiner's Initials	BT	
11765 : Selected art patent for oxide sacrificial material in semiconductor device fabrication		
U.S. DEPT. OF COMM./PAT & TM-PTO-437(L)Rev. 12-94		

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
		Total Claims 7 Pat. 7 Print. 0.4	
Assistant Examiner		DRAWINGS	
		Sheets Drawn.	Fig. Drawn.
Primary Examiner		Print Fig.	
PREPARED FOR ISSUE		Application Examiner	
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